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Patent Application No. 10/714,304  
Customer Number: 42717  
Reply to Office action of August 23, 2005

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant:	Chao-Cheng Chen, et al.	§	Docket No.:	24061.475 / 2002-0210
Serial No.:	10/714,304	§	Examiner:	Michelle Estrada
Filed:	November 14, 2003	§	Art Unit:	2823
For:	Dual Damascene Process Flow for Porous Low-K Materials	§	Conf. No.:	2110

Commissioner for Patents  
Mail Stop Amendment  
P.O. Box 1450  
Alexandria, VA 22313-1450

AMENDMENT

Dear Sir:

In response to the Final Office Action of August 23, 2005, please amend the above-identified application as follows:

**Amendments to the Claims** are reflected in the listing of claims which begins on page 2 of this paper.

**Remarks/Arguments** begin on page 11 of this paper.

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